

AMENDMENTS TO THE CLAIMS

1. (Currently amended) A quantum-dot LED comprising :
an n-type semiconductor layer;
at least one insulator layer formed on the n-type semiconductor layer and provided with a plurality of holes;
quantum dots formed by filling the holes; and
a p-type semiconductor layer formed on the insulator layer in which the quantum dots are formed,
wherein the p-type semiconductor layer is contacted with the quantum dots, or both the n-type semiconductor layer and the p-type semiconductor layer are contacted with the quantum dots, and
wherein the insulator layer comprises a first insulator layer formed on the n-type semiconductor layer and a second insulator layer formed on the first insulator layer, and the quantum-dot LED comprises a barrier layer inserted between the first insulator layer and the second insulator layer.
2. (Canceled).
3. (Currently Amended) The quantum-dot LED according to ~~claim 2~~claim 1, wherein the first and second insulator layers formed interposing the barrier layer therebetween has a multi-layer structure.
4. (Currently Amended) The quantum-dot LED according to ~~claim 2~~claim 1, wherein the barrier layer is of one selected from the group consisting of GaN, GaAs and GaP.
5. (Previously Presented) The quantum-dot LED according to claim 1, wherein the holes are nano-holes.

6. (Original) The quantum-dot LED according to claim 1, wherein the holes have a size range of 1 nanometer to 100 nanometers.

7. (Original) The quantum-dot LED according to claim 1, wherein the quantum dots are formed from one selected from the group consisting of InGaN, InGaAs and InGaP.

8. (Previously Presented) The quantum-dot LED according to claim 1, wherein the quantum dots comprise an upper surface being in direct contact with the p-type semiconductor layer, and a lower surface being in direct contact with the n-type semiconductor layer.

9. (Original) The quantum-dot LED according to claim 1, wherein the size and/or density of the holes are/is determined by deposition time of the insulator layer.

10. (Currently Amended) A method for fabricating a quantum-dot LED, the method comprising the steps of:

forming an n-type semiconductor layer;

depositing a first insulator layer having first holes on the n-type semiconductor layer;

filling the first holes of the first insulator layer to form first quantum dots, wherein (a) after the step of forming the quantum dots, forming a barrier layer on the insulator layer in which the quantum dots are formed; (b) forming a second insulator layer having second holes on the barrier layer; and (c) filling the second hole of the second insulator layer to form second quantum dots, wherein the steps (a), (b) and (c) are repeated at least once; and

depositing a p-type semiconductor layer on the first insulator layer in which the quantum dots are formed,

wherein the p-type semiconductor layer is contacted with the quantum dots, or both the n-type semiconductor layer and the p-type semiconductor layer are contacted with the quantum dots.

11. (Canceled).

12. (Original) The method according to claim 10, wherein in the step of depositing the insulator layers, the size and/or density are/is determined by deposition time of the insulator layer.

13. (Canceled).

14. (Previously Presented) The method according to claim 10, wherein the first quantum dots comprise an upper surface being in direct contact with the p-type semiconductor layer, and a lower surface being in direct contact with the n-type semiconductor layer.

15. (Canceled).

16. (Currently Amended) A quantum-dot LED comprising:
an n-type semiconductor layer;
at least one insulator layer formed on the n-type semiconductor layer and provided with a plurality of holes;
quantum dots formed by filling the holes; ~~and~~
a barrier layer formed on the insulator layer and quantum dots; and
a p-type semiconductor layer formed on the insulator layer in which the quantum dots are formed;
~~wherein the n-type semiconductor layer and the p-type semiconductor layer are contacted with the quantum dots.~~

17. (Previously Presented) The quantum-dot LED according to claim 16, wherein the top surface of the quantum dots and the top surface of the insulator layer are formed on same horizontal plane and the bottom surface of the quantum dots and the bottom surface of the insulator layer are formed on same horizontal plane.

18. (Previously Presented) The quantum-dot LED according to claim 16, wherein the quantum dots are directly contacted with the n-type semiconductor layer formed under the quantum dots.